

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: C. N. Kline

Group Art Unit: : IBM Corporation
Examiner: : Intellectual Property Law
Serial No.: : Dept. IQ0A/Bldg. 040-3
Filed: Herewith : 1701 North Street
Title: SYSTEM, METHOD AND Endicott, NY 13760
PROGRAM PRODUCT FOR MANAGING
PRIVILEGE LEVELS IN A COMPUTER
SYSTEM

Assistant Commissioner For Patents

Washington, D.C. 20231

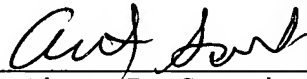
Dear Sir:

INFORMATION DISCLOSURE STATEMENT

It is respectfully requested that the publications identified on the enclosed PTO-1449 Form(s) be considered by the United States Patent and Trademark Office (USPTO) in the subject United States patent application and be made of record herein.

Respectfully submitted,

Dated: March 1, 2004
Telephone: 607-429-4368
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By: 
Arthur J. Samodovitz
Reg. No. 31,297

INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

Docket Number (Optional)

END920030127US1

Application Number

Applicant(s)

C. N. Kline

Filing Date

Herewith

Group Art Unit

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		US 2002/0026591 A1	2/28/02	B. V. Hartley et al	713	201	04/12/01
		US 2002/0095591 A1	7/18/02	W. T. anielle t al	713	200	01/12/01
		US 2003/0115446 A1	06/19/03	K. D. Simon et al	713	100	12/17/01
		6,014,666	01/11/00	P. J. Helland et al	707	9	10/28/97
		6,185,689	02/06/01	R. F. Todd et al	713	201	6/24/98
		6,233,576	05/15/01	J. R. Lewis	707	9	09/25/95

FOREIGN PATENT DOCUMENTS

REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

		ION Secure TM 3500 G2-SIE, ION Netowrks, Inc., Piscataway, NJ 2002
		MQSeries Planning Guide, IBM Corp. 1999
		Candle Corp's MQSecure, EAI Journal, Jun 2002, http://www.bijonline.com/PDF/FIMQSecure.pdf .

EXAMINER	DATE CONSIDERED
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.